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APPLICATION NO.		FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/642,929		08/18/2003	Kenji Sakai	2281.2.15	3856
21552	7590	05/05/2005		EXAMINER	
MADSON			GOUDREAU, GEORGE A		
GATEWAY SUITE 900	TOWER	RWEST	1	ART UNIT	PAPER NUMBER
15 WEST S			1763		
SALT LAK	E CITY,	UT 84101	DATE MAILED: 05/05/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)					
	10/642,929	SAKAI ET AL.					
Office Action Summary	Examiner	Art Unit					
	George A. Goudreau	1763					
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the d	correspondence ac	ddress				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be tir within the statutory minimum of thirty (30) day vill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered time the mailing date of this o D (35 U.S.C. § 133).	ely. communication.				
Status							
Responsive to communication(s) filed on <u>21 Ja</u> This action is FINAL . 2b)⊠ This Since this application is in condition for allowar closed in accordance with the practice under E	action is non-final. nce except for formal matters, pro	•	e merits is				
Disposition of Claims							
4) ☐ Claim(s) 1-24 is/are pending in the application. 4a) Of the above claim(s) 11-24 is/are withdraw 5) ☐ Claim(s) 2-4, and 7-10 is/are allowed. 6) ☐ Claim(s) 1,5 and 6 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	n from consideration.						
Application Papers	·						
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the Replacement drawing sheet(s) including the correction of the output of of the	epted or b) objected to by the drawing(s) be held in abeyance. Se ion is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 C	* *				
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the second section for a list of the section for a list of the second section for a list of the second section for a list of the section for a list of the second section for a list of the second section for a list of the	or the certified copies not receive	eu. GEO PRIM	RGE GOUDPIEAU MARY EXAMINER				
Attachment(s) 1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)	1-02				
2) Notice of References Cited (FTO-092) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mail D 5) Notice of Informal F 6) Other:	ate	O-152)				

U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04) Art Unit: 1763

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1, and 5-6 are rejected under 35 U.S.C. 102(b) as being anticipated by Ina et. al. (6,315,803).

Ina et. al. disclose a three step cmp polishing process for forming a Cu damascene with an underlying Ta barrier layer on the surface of a wafer which is comprised of the following steps:

- -The bulk of the Cu layer is cmp polished in a first cmp polishing process, which employs a cmp slurry comprised of colloidal silica abrasive particles, H2O2, H2O, and glycine.;
- -The remainder of the Cu layer is cmp polished down to the top of the Ta barrier layer in a second cmp polishing process which employs a cmp slurry comprised of abrasive colloidal silica particles, H2O2, oxalic acid, BTA, EDTA, and H2O.; and
- -The Ta barrier layer is cmp polished down to the surface of the ILD layer in a third cmp polishing process which employs a cmp slurry which is comprised of abrasive colloidal silica particles, oxalic acid, BTA, EDTA, and H2O with no H2O2 being present.

This is discussed specifically in columns 13-16; and discussed in general in columns 1-20.

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3. Claims 2-4, and 7-10 are allowed.

The prior art made of record and not relied upon is considered pertinent to 4. applicant's disclosure.

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Any inquiry concerning this communication should be directed to examiner 5. George A. Goudreau at telephone number (571)-272-1434.

Geørge A. Goudreau Primary Examiner

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